

Supporting Information for

Al-Doped Nickel Sulfide Nanosheet Arrays as Highly-Efficient
Bifunctional Electrocatalysts for Overall Water Splitting

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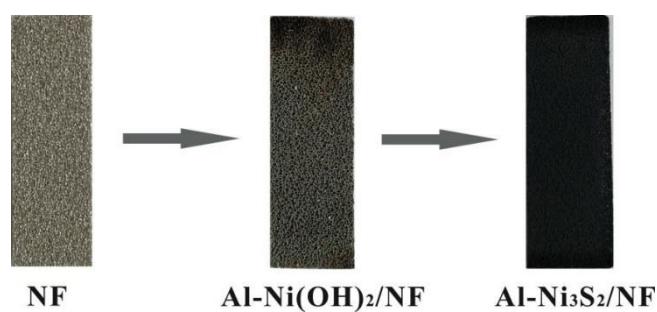


Fig. S1. Photographic images of Ni foam (NF), Al-Ni(OH)₂/NF and Al-Ni₃S₂/NF.

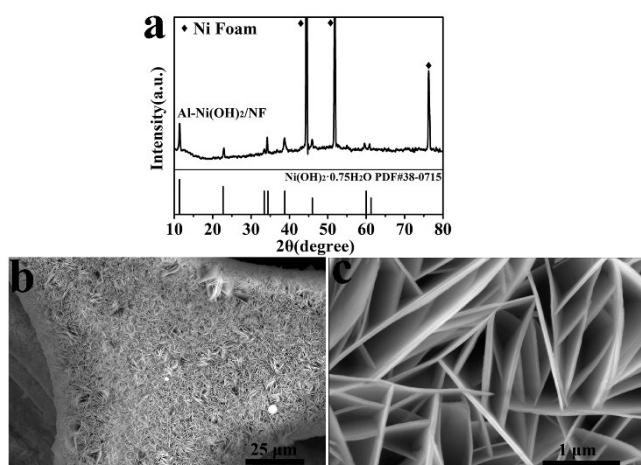


Fig. S2. (a) XRD, and (b-c) SEM images of Al-Ni(OH)₂/NF.

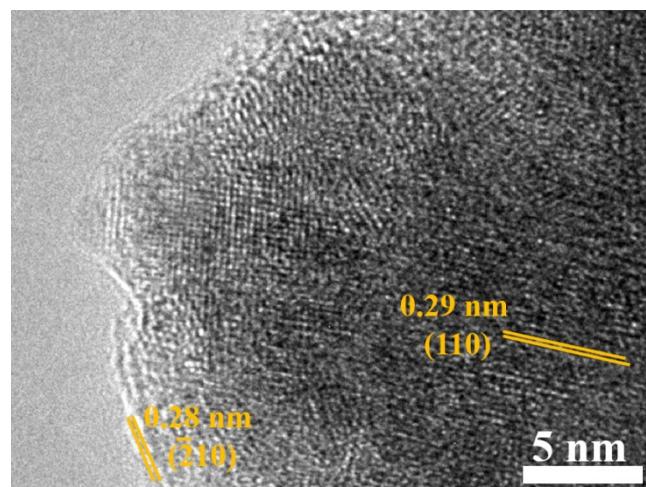


Fig. S3. HRTEM image of the edge of Al-Ni₃S₂/NF nanosheet.

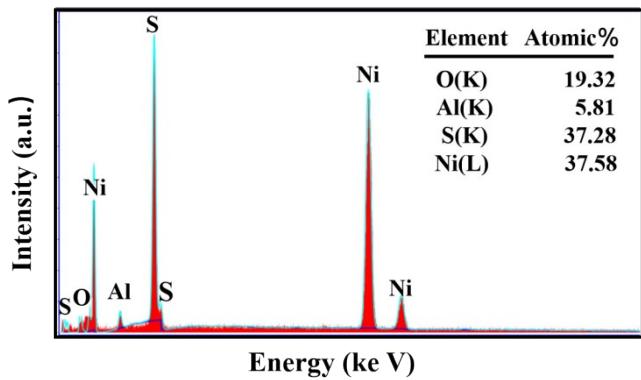


Fig. S4. EDS spectra of Al-Ni₃S₂/NF

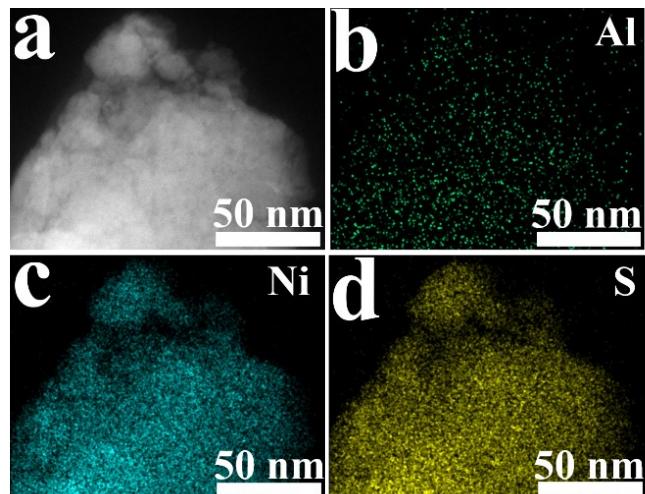


Fig. S5. (a) survey, (b) Al, (c) Ni, and (d) S elemental mapping images of Al-Ni₃S₂/NF.

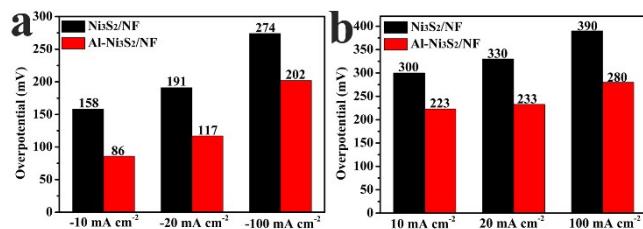


Fig. S6. The overpotential of Ni₃S₂/NF and Al-Ni₃S₂/NF at the current density of 10, 20 or 100 mA cm^{-2} for (a) HER, and (b) OER.

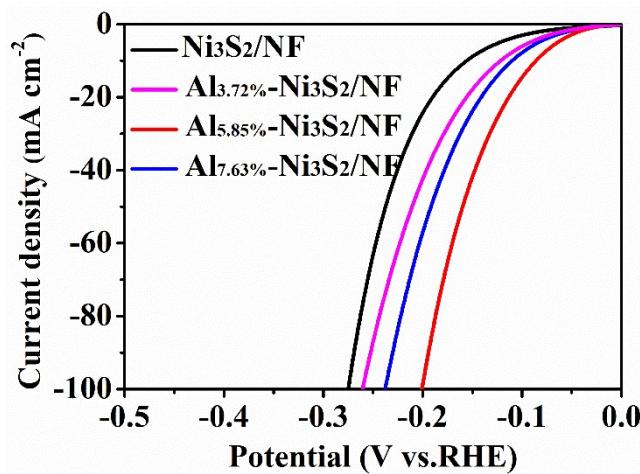


Fig. S7. The LSV curves of the HER performance of Al_x%-Ni₃S₂/NF (x=3.72, 5.85 and 7.63).

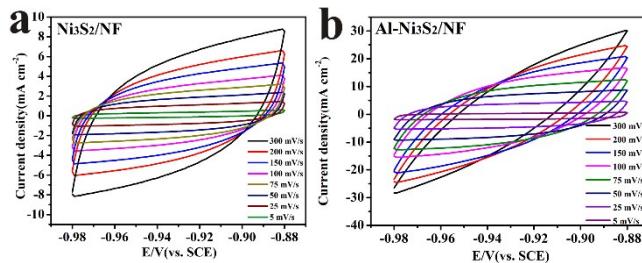


Fig. S8 Typical cyclic voltammetry curves of (a) Ni₃S₂/NF and (b) Al_{5.85}%-Ni₃S₂/NF with different scan rates in 1M KOH.

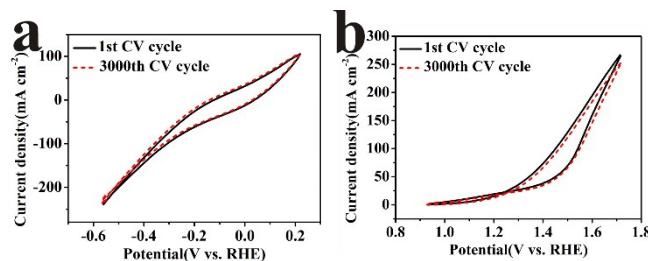


Fig. S9 The first and 3000th CV cycle curves of Ni₃S₂/NF and Al_{5.85}%-Ni₃S₂/NF for (a) HER and (b) OER.

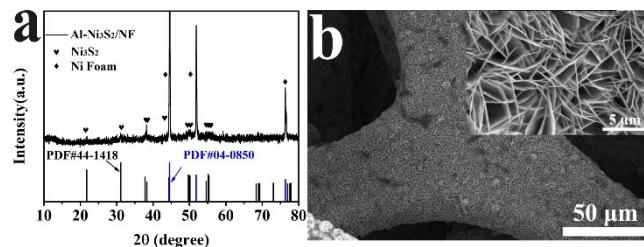


Fig. S10 (a) XRD pattern and (b) SEM of Al_{5.85}%-Ni₃S₂/NF after HER.

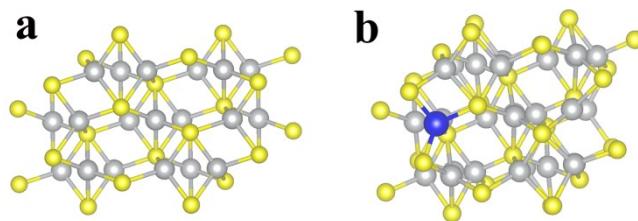


Fig. S11. Top views of the (210) surface and of (a) Ni₃S₂/NF and (b) Al-Ni₃S₂.

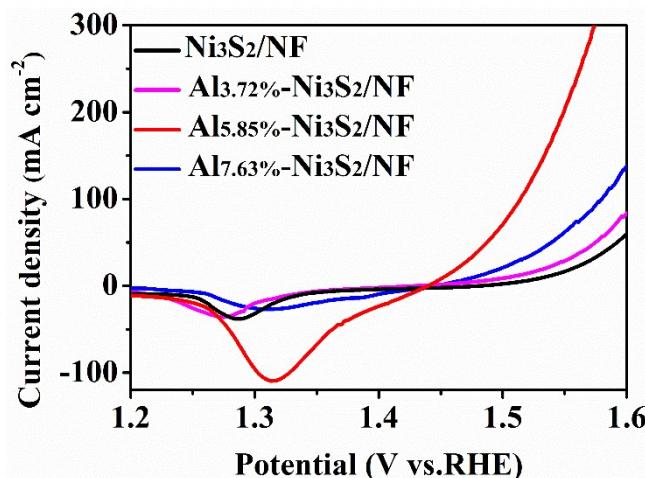


Fig. S12. The LSV curves of the OER performance of Al_x%-Ni₃S₂/NF (x=3.72, 5.85 and 7.63).

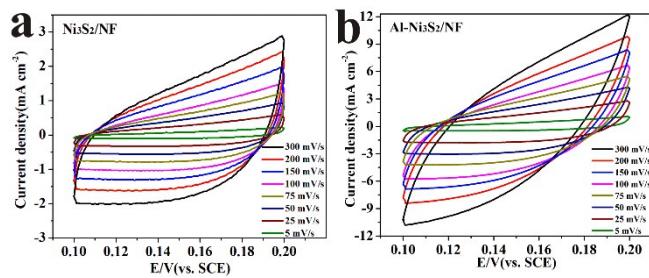


Fig. S13 Typical cyclic voltammetry curves of (a) $\text{Ni}_3\text{S}_2/\text{NF}$ and (b) $\text{Al}_{5.85\%}\text{-}\text{Ni}_3\text{S}_2/\text{NF}$ with different scan rates in 1M KOH.

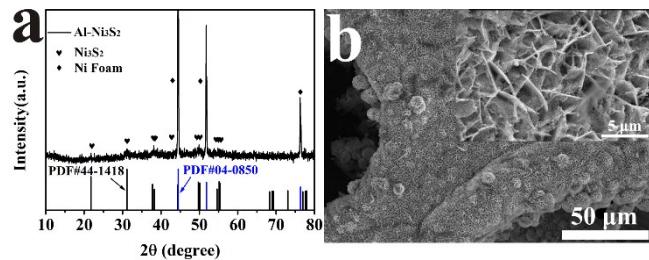


Fig. S14 (a) XRD pattern and (b) SEM of $\text{Al}_{5.85\%}\text{-}\text{Ni}_3\text{S}_2/\text{NF}$ after OER.

Table S1. The chemical composition of Al-Ni₃S₂ and Ni₃S₂ measured by XPS.

Samples	Atomic Percentage (At %)				F Doping concentration (At %)
	Ni	Al	S	O	$\frac{n(Al)}{n(Al) + n(Ni)}$
Ni ₃ S ₂	14.45	--	9.72	29.02	--
Al _{5.85%} -Ni ₃ S ₂	14.30	0.89	9.49	28.72	5.85

Table S2. Comparison of the HER performance of Al_{5.85%}-Ni₃S₂/NF with other reported catalysts in 1 M KOH.

Catalysts	Overpotential at			Tafel slope	References
	10 mA cm ⁻²	20 mA cm ⁻²	100 mA cm ⁻²	mV dec ⁻¹	
Al _{5.85%} -Ni ₃ S ₂ /NF	86	117	202	75	This work
MoS ₂ /Co ₉ S ₈ /Ni ₃ S ₂ /Ni	113	--	--	58	¹
Ni ₃ S ₂ /MnO ₂ /NF	102	--	197	69	²
P _{9.03%} -(Ni, Fe) ₃ S ₂ /NF	98	135	218	88	³
Fe _{17.5%} - Ni ₃ S ₂ /NF	47	142	232	95	⁴
Sn-Ni ₃ S ₂ /NF	137	200	320	51	⁵
V-Ni ₃ S ₂ /NF	--	203	350	112	⁶
Ni _{1.5} Fe _{0.5} P/CF	158	--	319	125	⁷

Table S3. Comparison of the OER performance of Al_{5.85%}-Ni₃S₂/NF with other reported catalysts in 1 M KOH.

Catalysts	Overpotential at			Tafel slope	References
	10 mA cm ⁻²	20 mA cm ⁻²	100 mA cm ⁻²	mV dec ⁻¹	
Al _{5.85%} -Ni ₃ S ₂ /NF	223	233	280	37	This work
Ni/NiS	--	320	390	109.03	8
Ni _{1.5} Fe _{0.5} P/CF	--	--	293	55	7
Fe-Ni ₃ S ₂ /FeNi	282	--	--	54	9
NiFe LDH@NiCoP/NF	220	--	--	48.6	10
P _{9.03%} -(Ni, Fe) ₃ S ₂ /NF	196	202	242	30	3
MoS ₂ /Ni ₃ S ₂	218	--	290	88	11
NC–NiCu–NiCuN	232	--	295	41	12

Table S4. Comparison of the Overall water splitting performance of Al_{5.85%}-Ni₃S₂/NF with other well-performed electrocatalysts.

Catalysts	Overpotential at			References
	10 mA cm ⁻²	20 mA cm ⁻²	100 mA cm ⁻²	
Al _{5.85%} -Ni ₃ S ₂ /NF	1.58 V	1.63 V	1.80 V	This work
Fe _{11.1%} -Ni ₃ S ₂ /NF	1.60 V	1.66 V	--	13
P _{9.03%} -(Ni, Fe) ₃ S ₂ /NF	1.54 V	1.58 V	1.72 V	3
MoS ₂ /Ni ₃ S ₂	1.56 V	--	--	11
Ni _{1.5} Fe _{0.5} P/CF	1.54 V	1.58 V	1.72	7

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